

IN THE SPECIFICATION:

Please revise the specification as follows:

Field of Invention

The present invention relates generally to the fields of digital circuits and electronics. More particularly, it relates to a Schmitt trigger circuit that has adjustable trip point voltages and that is suitable for use with different power supply signal levels.

Background of the Invention

In a digital system, signals typically take on one of two values, i.e., high or low, depending on the voltage level of the signal. Ideally, digital signals do not depart significantly from their expected voltage levels, but in practice digital systems usually operate under noisy conditions where there are signals unrelated to the signal of interest. In some cases, the noise level can be so large that false switching occurs, resulting in a meta-stable environment in which a digital low signal appears as a digital high signal, or vice-versa.

A common approach to eliminating or reducing the effects of noise in a digital system is to employ logic circuitry in which the output voltage as a function of input voltage, i.e., the voltage transfer characteristic (VTC), uses a hysteresis detection scheme instead of a single (or fixed) trip point detection scheme. In a VTC with hysteresis, there are two different logic trip points at which the output changes state: an upper trip point (V_{T+}) for low level input signals that are rising, and a lower trip point (V_{T-}) for high level input signals that are falling. In between the logic trip points, a deadband region exists. The width of the deadband region in the VTC is referred to as the hysteresis voltage and equals $V_{T+} - V_{T-}$.

In digital technology, an input detected using hysteresis is generally referred to as a Schmitt-triggered input, and a circuit which uses such detection as a Schmitt trigger circuit. Schmitt trigger circuits typically use regenerative, i.e., positive, feedback to convert a noisy or slow-changing input signal into a clean, sharply changing digital output signal. Schmitt triggers are commonly employed in various types of logic circuits, simple examples of which are inverting and non-inverting buffers. Due to the hysteresis characteristic of a Schmitt trigger circuit, once the input crosses a trip point and causes the output state to change, any noise in the input will not affect the output logic state as long as noise pulses are smaller than the hysteresis

voltage. In contrast, in a single (i.e., fixed) trip point circuit, the output may undesirably switch states several times when the input is near the trip point level, even in the presence of only small noise pulses. A Schmitt trigger's hysteresis voltage, $V_{T+} - V_{T-}$, thus provides a noise margin indicative of the amount of noise that can be tolerated without registering false output states. It is generally desirable for the noise margin to be large. However, if the upper trip point voltage is set too high and/or the lower trip point voltage is set too low, actual input voltage transitions may be unduly delayed at the output or, worse yet, not recognized at all.

The hysteresis voltage (i.e., noise margin) and the specific trip point voltages V_{T+} and V_{T-} of a Schmitt trigger circuit are dependent on the power supply voltage V_{CC} driving the circuit. For a given V_{CC} level, a Schmitt trigger circuit can be designed to provide a desired hysteresis voltage and trip point voltages. However, in many digital circuits such as programmable logic devices, the V_{CC} level may vary considerably depending on the application. For instance, Schmitt trigger circuits are commonly used in input/output (I/O) circuit applications where a V_{CC_IO} supply may vary from 1.5 V to 5.0 V depending on the logic family and I/O standard being used. If a Schmitt trigger circuit is designed to operate for a given V_{CC} voltage, when the value of V_{CC} changes by a significant amount, the hysteresis voltage and specific trip point voltage levels may no longer satisfy desired noise margin, delay, and input recognition criteria. Consequently, there is a need for a Schmitt trigger circuit that can meet desired hysteresis criteria at more than one V_{CC} voltage level.

Summary of the Invention

The present invention provides a Schmitt trigger circuit with an adjustable hysteresis characteristic by providing a plurality of ~~feedback control~~ circuits that differently affect at least one, and preferably both, of the circuit's upper trip point level and lower trip point level. The upper trip point level can be adjusted by selecting a desired ~~feedback control~~ circuit from a first set of ~~feedback control~~ circuits, and the lower trip point level can be adjusted by selecting a desired ~~feedback control~~ circuit from a second set of ~~feedback control~~ circuits. In this manner, the hysteresis characteristic can be adjusted to meet desired noise margin, delay, and input recognition criteria at different V_{CC} levels.

The invention provides a Schmitt trigger circuit having a first transistor coupled between a reference node and a first node, a second transistor coupled between the first node and a second

node, a third transistor coupled between the second node and a third node, and a fourth transistor coupled between the third node and a power supply signal node. Each of the first, second, third, and fourth transistors has a control (e.g., gate) terminal for receiving an input signal. A first plurality of feedback control circuits selectively provides a first feedback control path between the second node and the first node. Each of those feedback control circuits receives a control signal so that only one of the first plurality of feedback control circuits provides the first feedback control path at any one time. Similarly, a second plurality of feedback control circuits selectively provides a feedback control path between the second node and the third node. Each of these feedback control circuits also receives a control signal so that, again, only one of the second plurality of feedback control circuits provides the second feedback control path at any one time.

Each feedback control circuit in the first plurality of feedback control circuits may have a first feedback control transistor and a second feedback control transistor. The first feedback control transistor has a control terminal coupled to the second node and is coupled between the power supply signal node and the second feedback control transistor. The second feedback control transistor has a control terminal for receiving the control signal provided to the corresponding feedback control circuit, with the second feedback control transistor being coupled between the first feedback control transistor and the first node.

Similarly, each feedback control circuit in the second plurality of feedback control circuits may have a first feedback control transistor and a second feedback control transistor. The first feedback control transistor has a control terminal coupled to the second node and is coupled between the reference node and the second feedback control transistor. The second feedback control transistor has a control terminal for receiving the control signal provided to the corresponding feedback control circuit, and the second feedback control transistor is coupled between the first feedback control transistor and the third node.

In one embodiment, the first transistor, the second transistor, and the feedback control transistors in each feedback control circuit in the first plurality of feedback control circuits are n-channel metal oxide semiconductor field-effect transistors, and the third transistor, the fourth transistor, and the feedback control transistors in each feedback control circuit in the second

plurality of feedback control circuits are p-channel metal oxide semiconductor field-effect transistors.

By, for example, varying the combined conductivity of the feedback control transistors in the control circuits and/or varying the threshold voltages of the first feedback control transistor in the feedback control circuits, the feedback control circuits can be designed to provide different upper and/or lower trip point levels.

Brief Description of the Drawings

The objects and advantages of the present invention will be better understood and more readily apparent when considered in conjunction with the following detailed description and accompanying drawings which illustrate, by way of example, preferred embodiments of the invention and in which:

Fig. 1 is a circuit diagram of a prior art CMOS Schmitt trigger circuit;

Fig. 2 is a plot of the voltage transfer characteristic of the circuit of Fig 1 at a first power supply signal level;

Fig. 3 is a plot of the voltage transfer characteristic of the circuit of Fig 1 at a second power supply signal level;

Fig. 4 is a circuit diagram of a CMOS Schmitt trigger circuit having a plurality of selectable feedback control circuits in accordance with an embodiment of the present invention; and

Fig. 5 is a plot illustrating how, for the circuit of Fig. 4, the voltage transfer characteristic may differ at the second power supply signal level by selecting a different set of feedback control circuits.

Detailed Description of Preferred Embodiments

Fig. 1 is a circuit diagram of a prior art Schmitt trigger circuit 10 implemented using CMOS (complementary metal-oxide semiconductor) technology in which n-channel (NMOS) and p-channel (PMOS) metal oxide semiconductor field-effect transistors are combined, typically on a common substrate. CMOS-based implementations of Schmitt triggers are generally advantageous since they provide a high input impedance, can be readily designed to have threshold voltages that are roughly symmetrical to one-half the supply voltage, consume

low power, and are easily integrated with other CMOS circuitry. CMOS Schmitt Triggers are discussed, for example, in "CMOS Schmitt Trigger B A Uniquely Versatile Design Component", *Fairchild Semiconductor Application Note* 140 (June 1975) and in Kuang et al., "PD/SOI CMOS Schmitt Trigger Circuits with Controllable Hysteresis", *International Symposium on VLSI Technology, Systems, and Applications*, Hsinchu, Taiwan (April 2001), and the contents of each are incorporated herein by virtue of this reference.

Referring to Fig. 1, Schmitt trigger circuit 10 includes four NMOS transistors T0, T1, T2, and T20 and four PMOS transistors T3, T4, T5, and T21. Transistors T0, T1, T4, and T5 provide an first inversion stage, transistors T2 and T3 are feedback control transistors, and transistors T20 and T21 form a second inversion stage 20. As will be appreciated by those of ordinary skill in the art, Schmitt trigger circuit 10 may form part of a buffer circuit, inverter circuit, or any other type of logic circuit. In particular, Schmitt trigger circuit 10 may be used in input/output circuit applications to improve signal transitions and enhance noise immunity.

As shown in Fig. 1, an input signal VIN is applied to the gate (i.e., control) terminals of each of transistors T0, T1, T4, and T5. The source terminal of NMOS transistor T0 is connected to the most negative supply reference VSS (which is typically ground, i.e., 0 V), and the drain terminal of transistor T0 is connected to the source terminal of NMOS transistor T1 at a node 50. The source terminal of PMOS transistor T4 is connected to a positive power supply signal VCC, and the drain terminal of transistor T4 is connected to the source terminal of PMOS transistor T5 at a node 40. The drain terminals of transistors T1 and T5 are connected together at a node 30. NMOS transistor T2 provides a feedback control path from node 30 to node 50. The gate terminal of transistor T2 is connected to node 30, its drain terminal is connected to VCC, and its source terminal is connected to node 50. Similarly, PMOS transistor T3 provides a feedback control path from node 30 to node 40. The gate terminal of transistor T3 is connected to node 30, while the drain terminal of transistor T3 is connected to VSS and its source terminal is connected to node 40. As will be appreciated by those skilled in the art, because of the symmetry of standard MOS transistors, the designation of source and drain in transistors T2 and T3 is not critical, but rather is used for ease of description.

Node 30 is also connected to the input of inverter stage 20 which comprises an NMOS transistor T20 having its source coupled to VSS and a PMOS transistor T21 with its source

coupled to VCC. The gates of transistors T20 and T21 receive the signal at node 30, and the drains of transistors T20 and T21 are connected together to provide a node for the Schmitt trigger output signal VOUT.

Where a CMOS IC device is implemented on a p-type substrate, a PMOS transistor is typically formed within an n-well, i.e., a well of n-type material, in the p-type substrate. Similarly, if an IC device is fabricated on an n-type substrate, an NMOS transistor is formed within a p-type doped well in the n-type substrate. In addition, the body of a MOS transistor, effectively the channel or substrate of the transistor, is usually connected to VCC or VSS. More specifically, the p-type body of an NMOS transistor is usually connected to the most negative supply in the device (i.e., VSS), while the n-type body of a PMOS transistor is usually connected to the most positive voltage in the device (i.e., VCC). Thus, though not specifically indicated in Fig. 1, the body terminals of NMOS transistors T0, T1, T2, and T20 are connected to VSS and the body terminals of PMOS transistors T3, T4, T5, and T21 are connected to VCC.

The threshold voltage V_{th} of a MOSFET transistor is generally the lowest gate-to-source (or source-to-gate) voltage that causes a substantial current to flow through the transistor. The threshold voltage is positive for an NMOS transistor (V_{thn}) and negative for a PMOS transistor ($-V_{thp}$). In effect, the transistor turns on when $V_{gs} > V_{thn}$ for an NMOS transistor and $V_{sg} > V_{thp}$ for a PMOS transistor, where V_{gs} is the gate-to-source voltage and V_{sg} is the source-to-gate voltage. The threshold voltage of a transistor varies depending on a number of factors including the semiconductor manufacturing process used and operating temperature. In addition, the body biasing effect, an effect in integrated circuits that depends in part on the voltage between the source and body of the transistor when the two are not tied together, may also increase the effective threshold for turning on a MOS transistor beyond the design-specified V_{th} parameter. Typical threshold voltages for the transistors in Fig. 1 may be in the range of 0.3 to 1.0 V. Commonly, NMOS transistors T0, T1, and T2 are designed to have the same intrinsic threshold voltage V_{thn} (i.e., ignoring the body bias effect), and similarly PMOS transistors T3, T4, and T5 are designed to have the same threshold voltage V_{thp} . However, it will be appreciated that the threshold voltages of these ~~transistor~~ transistors may also be designed to differ.

The operation of Schmitt trigger circuit 10 will now be described. Generally, transistors T0, T1, T4, and T5 effectively act as a CMOS inverter by providing an inverted VIN signal at node 30. The second inverter stage 20 thus renders the overall Schmitt trigger circuit 10 non-inverting, since $V_{IN} = V_{OUT}$ during steady state operation. Alternatively, inverter stage 20 may be omitted, in which case trigger circuit 10 provides an inverted output signal. Schmitt trigger circuit 10 may also include additional circuitry (not shown) such as latch or flip-flop circuitry for better holding the steady state level of VOUT.

When the VIN signal to trigger circuit 10 is low (i.e., at or near VSS), transistors T0 and T1 are off while transistors T4 and T5 turn on. As a result, the voltage at node 30 is pulled high, approximately to VCC. Since the gates of ~~feedback control~~ transistors T2 and T3 are high, PMOS transistor T3 is off while NMOS transistor T2 turns on. As will be appreciated by those skilled in the art, transistor T2 acts as a source follower when on since the drain of T2 is tied to the DC supply, VCC. As a result, the voltage at the source of transistor T2 (i.e., node 50) follows the voltage at its gate (i.e., node 30) minus a voltage drop that is approximately equal to the threshold voltage V_{thn} of transistor T2. As VIN rises at the onset of a low to high transition, the voltage at the gate of NMOS transistor T0 eventually increases above V_{thn} , turning transistor T0 on. However, since the source terminal of NMOS transistor T1 is higher than the body of transistor T1, the body biasing effect raises the effective threshold of transistor T1, and therefore transistor T1 remains off when transistor T0 initially turns on. Since transistors T2 and T0 are both on, they effectively form a voltage divider between node 30 and VSS at node 50. If transistors T2 and T0 are matched in terms of their conductivity parameters, the voltage at node 50 is roughly half the voltage at node 30, i.e., $\frac{1}{2} VCC$.

As VIN continues to rise and increases to one threshold voltage V_{thn} above the voltage at node 50 (i.e., $\frac{1}{2} VCC + V_{thn}$, if T2 and T0 are matched), NMOS transistor T1 turns on, and the voltage at node 30 is pulled low toward VSS. This starts a low to high transition in VOUT. As the voltage at node 30 falls, the source-following behavior of transistor T2 now acts to pull node 50 low and the influence of the voltage divider rapidly disappears, further lowering node 30. As the voltage at node 30 decreases, PMOS transistor T3 begins to turn on. Since transistor T3 also acts a source follower, the voltage at node 40 is also pulled low following the voltage at node 30. As a result, since the voltage at the source terminal of PMOS transistor T5 is low, transistor T5

turns off and node 30 is rapidly tied to VSS. As VIN continues to rise, PMOS transistor T4 also turns off. The voltage at node 30 is therefore held at a low level and, consequently, the output voltage VOUT is high.

With VIN high, the voltage at node 40 is approximately V_{thp} due to the source follower behavior of the conducting PMOS ~~feedback control~~ transistor T3. When VIN begins falling from its high level at the onset of a high to low transition, Schmitt trigger circuit 10 operates in a similar manner to that described above. In particular, when VIN falls more than one V_{thn} below VCC, PMOS transistor T4 turns on. PMOS transistor T5 remains off at this stage, since the body biasing effect increases the effective turn-on threshold of transistor T5. With transistor T3 and T4 both on, a voltage divider is effectively formed at node 40, dividing the voltage between VCC and node 30. If transistors T3 and T4 are matched in terms of their conductivity parameters, the voltage at node 40 will be roughly $\frac{1}{2}$ VCC. As VIN continues to fall and decreases to a threshold voltage V_{thp} below the voltage at node 40 (i.e., $\frac{1}{2}$ VCC - V_{thp}), PMOS transistor T5 turns on, and the voltage at node 30 is pulled high toward VCC. At this point, a high-to-low transition in VOUT begins. With the voltage at node 30 rising, the source-following behavior of transistor T3 further acts to pull node 40 high, effectively ending the influence of the voltage divider formed by T3 and T4. As the voltage at node 30 continues to rise, NMOS ~~feedback control~~ transistor T2 begins to turn on, and the voltage at node 50 is also pulled high due to the effect of ~~feedback control~~ transistor T2. As a result, NMOS transistor T1 shuts off and the voltage at node 30 is rapidly brought to VCC. Further increases in VIN act to shut off NMOS transistor T0, and circuit 10 subsequently stabilizes with node 30 held high and VOUT held low.

Fig. 2 illustrates the hysteresis effect provided by Schmitt trigger circuit 10. As shown, the VTC of circuit 10 has two different logic trip points: an upper trip point V_{T+} at which a rising VIN signal triggers a high level VOUT signal, and a lower trip point V_{T-} at which a falling VIN signal triggers a low level VOUT signal. The specific voltage values at which a high and low output states are recognized may vary. For example, it is common in CMOS circuits for a high output state to be recognized when $V_{OUT} > 0.7$ VCC and a low output state to be recognized when $V_{OUT} < 0.3$ VCC, in which case $V_{OUT} = 0.7$ VCC at V_{T+} and $V_{OUT} = 0.3$ VCC at V_{T-} .

In view of the operation of Schmitt trigger circuit 10 described above, it will be appreciated that V_{IN} reaches the upper trip point V_{T+} approximately when NMOS transistor T1 turns on. Where the conductivity of transistors T2 and T0 is matched, this occurs when $V_{IN} = V_{T+} \approx \frac{1}{2} V_{CC} + V_{thn}$. Similarly, V_{IN} reaches the lower trip point V_{T-} approximately when PMOS transistor T5 first turns on. This occurs at about $V_{IN} = V_{T-} \approx \frac{1}{2} V_{CC} - V_{thp}$ if the conductivity of transistors T3 and T4 is matched. Thus, by increasing the threshold voltage of NMOS transistor T1, V_{T+} can be increased, and by increasing the magnitude of the threshold voltage of PMOS transistor T5, V_{T-} can be decreased. Lowering these threshold voltages has the opposite effect.

However, the upper and lower trip point voltages of circuit 10 can also be varied by adjusting the device parameters of feedback control transistors T2 and T3 respectively. In particular, by increasing (or decreasing) the conductivity of NMOS transistor T2 relative to transistor T0, the upper trip point V_{T+} also increases (or decreases). Similarly, by increasing (or decreasing) the conductivity of PMOS transistor T3 relative to transistor T4, the lower trip point V_{T-} decreases (or increases). The conductivity of a MOSFET transistor may be raised by increasing the width-to-length ratio of the transistor's gate (i.e., its channel) and lowered by reducing that ratio. (Note the length of the gate is generally the distance between the source and the drain of the transistor.) Moreover, if the threshold voltage of feedback control transistor T2 is designed independently of transistors T0 and T1 and if threshold voltage of feedback control transistor T3 is designed independently of transistors T4 and T5, the feedback control transistor threshold voltages may also be adjusted to vary V_{T+} and V_{T-} . In this case, lowering the magnitude of the threshold voltage for transistor T2 generally serves to raise the upper trip point V_{T+} , and lowering the magnitude of the threshold voltage for transistor T3 generally serves to bring down the lower trip point V_{T-} .

For a given value of V_{CC} , e.g., $V_{CC} = 1.8$ V as indicated in Fig. 2, Schmitt trigger circuit 10 can thus be designed to provide a desired upper trip point voltage V_{T+} and lower trip point voltage V_{T-} . However, if V_{CC} is changed, e.g., to $V_{CC} = 3.3$ V as shown in the VTC of Fig. 3, the trip point voltages also change. (Note that Figs. 2 and 3 are not drawn to scale.) When V_{CC} changes, particularly by a large amount, the new trip point voltage levels may not satisfy

desired noise margin criteria and/or they may lead to unwanted delay or even a failure to recognize legitimate input signal transitions.

This problem is overcome by Schmitt trigger circuit 100 in Fig. 4, which illustrates an embodiment of the present invention. Similar to circuit 10 in Fig. 1, Schmitt trigger circuit 100 includes an initial signal inversion stage that includes NMOS transistors T0 and T1 and PMOS transistors T4 and T5. However, in place of the fixed feedback control transistors T2 and T3 of the circuit of Fig. 1, circuit 100 includes two switchable NMOS transistor feedback control circuits 160 and 165 and two switchable PMOS transistor feedback control circuits 170 and 175. Switchable feedback control circuits 160, 165, 170, and 175 are controlled, or selected, by a VCCSEL signal. As shown, trigger circuit 100 may also include a subsequent output inverter stage 120 to render circuit 100 non-inverting. Inverter stage 120 includes NMOS transistor T20 and PMOS transistor T21, similar to stage 20 in circuit 10.

Referring to Fig. 4, input signal VIN is applied to the gate terminals of each of transistors T0, T1, T4, and T5. The source terminal of NMOS transistor T0 is connected to the most negative supply reference VSS (typically 0 V), and the drain terminal of transistor T0 is connected to the source terminal of NMOS transistor T1 at a node 150. The source terminal of PMOS transistor T4 is connected to a positive power supply signal VCC, and the drain terminal of transistor T4 is connected to the source terminal of PMOS transistor T5 at a node 140. The drain terminals of transistors T1 and T5 are connected together at a node 130.

NMOS transistor feedback control circuit 160 comprises two NMOS transistors T11 and T12. The gate terminal of transistor T12 is connected to node 130, its drain terminal is connected to VCC, and its source terminal is connected to the drain terminal of transistor T11. The source terminal of transistor T11 is connected to node 150, while the gate terminal of transistor T11 receives an inverted version \overline{VCCSEL} of control signal VCCSEL via an inverter 180. In a similar manner, NMOS transistor feedback control circuit 165 also comprises two NMOS transistors T13 and T14. The gate terminal of transistor T14 is connected to node 130, its drain terminal is connected to VCC, and its source terminal is connected to the drain terminal of transistor T13. The source terminal of transistor T13 is connected to node 150, and the gate terminal of transistor T13 receives control signal VCCSEL. Although not specifically indicated in Fig. 4, the body terminals of the NMOS transistors in circuit 100 are connected to VSS and the

body terminals of the PMOS transistors in circuit 100 are connected to VCC (similar to circuit 10).

PMOS transistor-~~feedback control~~ circuit 170 comprises two PMOS transistors T9 and T10. The gate terminal of transistor T10 is connected to node 130, its drain terminal is connected to VSS, and its source terminal is connected to the drain terminal of transistor T9. The source terminal of transistor T9 is connected to node 140, and the gate terminal of transistor T9 receives control signal VCCSEL. Similarly, PMOS transistor ~~feedback control~~ circuit 175 comprises two PMOS transistors T7 and T8. The gate terminal of transistor T8 is connected to node 130, its drain terminal is connected to VSS, and its source terminal is connected to the drain terminal of transistor T7. The source terminal of transistor T7 is connected to node 140, and the gate terminal of transistor T7 receives inverted control signal /VCCSEL.

When VCCSEL is low, the gate of PMOS transistor T9 is low and the gate of NMOS transistor T11 is high, while the gate of PMOS transistor T7 is high and the gate of NMOS transistor T13 is low. Thus, transistors T9 and T11 are on, while transistors T7 and T13 are off. As a result, when Schmitt trigger circuit 100 operates with VCCSEL low, ~~feedback control~~ circuits 160 and 170 are selected as the respective NMOS and PMOS ~~feedback control~~ paths from node 130 to nodes 150 and 140 respectively. On the other hand, when circuit operates in a high VCCSEL mode, ~~feedback control~~ circuits 165 and 175 are selected as the respective NMOS and PMOS ~~feedback control~~ paths from node 130. Unlike circuit 10, which had only one ~~feedback control~~ transistor in each path, in Schmitt trigger circuit 100 it will be appreciated that the cumulative effect of the transistors in a given ~~feedback control~~ circuit generally affects the hysteresis characteristic.

By using transistors with different conductivity parameters in NMOS ~~feedback control~~ circuits 160 and 165, the overall conductivity of those ~~feedback control~~ circuits can be made to differ. For example, if transistors T11 and T12 together provide a greater conductivity than transistors T13 and T14, Schmitt trigger circuit 100 will have a higher upper trip point V_{T+} (for a given VCC level) when ~~feedback control~~ circuit 160 is selected to provide the NMOS ~~feedback control~~ path. Similarly, if transistors T9 and T10 together provide a greater conductivity than transistors T7 and T8, Schmitt trigger circuit 100 will have a smaller lower trip point V_{T-} when

PMOS feedback control circuit 170 is selected than when feedback control circuit 175 is selected (again, assuming the same VCC level).

Additionally, if the respective threshold voltages of transistors T12 and T14 in NMOS feedback control circuits 160 and 165 are designed to differ, the two feedback control circuits will also yield different upper trip point voltage levels. In the same manner, if the threshold voltages of transistors T10 and T8 in PMOS-feedback control circuits 170 and 175 may have different values, each feedback control circuit will affect the lower trip point voltage level differently.

Thus, by providing two or more sets of switchable feedback control circuits in Schmitt trigger circuit 100, the hysteresis characteristic of the circuit can be adjusted independently of the VCC voltage level. For example, if the VTC illustrated in Fig. 3 corresponds to the selection of one set of feedback control circuits in Schmitt trigger 100 at a given VCC voltage level (in this case $V_{CC} = 3.3$ V), then the VTC characteristic illustrated in Fig. 5 may correspond to the selection of the other set of feedback control circuits in Schmitt trigger 100 for the same VCC level. As a result, a first set of NMOS and PMOS feedback control circuits (e.g., circuits 160 and 170) may be designed to provide desired trip point voltages for a first VCC level, and a second set of NMOS and PMOS feedback control circuits (e.g., circuits 160 and 170) can be designed to provide desired trip point voltages for a second VCC level. In this manner, desired noise margin, delay, and input recognition criteria may be readily met for different VCC voltage levels simply by setting the VCCSEL control signal to the appropriate level. Where circuit 100 is provided in a programmable logic device, VCCSEL may be a programmable signal to facilitate feedback control path selection within the device. Alternatively, a VCC level detection circuit (not shown) may be used to automatically detect the level of the VCC signal and set VCCSEL accordingly.

Furthermore, a Schmitt trigger circuit with more than two switchable sets of feedback control circuits may also be provided. For instance, circuit 100 may be adapted to have four PMOS feedback control circuits each with a corresponding NMOS feedback control circuit. In this case, two VCCSEL control signals (bits) are needed to select one of the four sets of feedback control circuits. Using basic logic circuitry, appropriate control signals may be provided to each feedback control circuit so that the VCCSEL signals select only one NMOS and only one PMOS feedback control circuit in each feedback control mode.

In another embodiment (not shown), PMOS feedback control circuits 170 and 175 may be replaced by a fixed feedback control path PMOS transistor, such as transistor T3 in circuit 10. In this case, only the NMOS feedback control path is switchable and only the upper trip point voltage level can be selectively adjusted. Alternatively, NMOS feedback control circuits 160 and 165 in circuit 100 may be replaced by a fixed feedback control path NMOS transistor, such as transistor T2 in circuit 10, limiting the adjustability of the hysteresis characteristic to the lower trip point voltage level.

Although the Schmitt trigger circuit of the present invention is particularly suitable for use with varying power supply signal levels, different sets of feedback control circuits may also be used to provide variable P/N ratios, even for the same VCC supply. The P/N ratio is the ratio of the PMOS transistor size to NMOS transistor size in the feedback control circuits. Where the gate lengths in the PMOS and NMOS transistors are the same, the P/N ratio equals the ratio of the PMOS gate width to the NMOS gate width.

A P/N ratio of about 2 roughly centers the hysteresis characteristic, since the conductivity of a PMOS transistor is about one-half that of an equivalently sized NMOS transistor. Thus, a set of feedback control circuits with a P/N ratio greater or less than 2 may provide a skewed hysteresis characteristic that favors rising or falling inputs. This may be desirable in high speed applications where one transition direction is more critical than the other.

While the invention has been described in conjunction with specific embodiments, it is evident that numerous alternatives, modifications, and variations will be apparent to those skilled in the art in light of the foregoing description.